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| APPLICATION NO. | FILING DATE | FIRST NAMED INVENTOR | ATTORNEY DOCKET NO. | CONFIRMATION NO. |
|-----------------------|------------------------------|----------------------|---------------------|------------------|
| 10/709,776 | 05/27/2004 | William G. America | FIS920040083US1 | 3775 |
| 45094 HOFFMAN WA | 7590 06/11/200 ARNICK LLC | EXAMINER | | |
| 75 STATE ST | | IM, JUNGHWA M | | |
| 14TH FL ALBANY, NY | 12207 | ART UNIT | PAPER NUMBER | |
| | | | 2811 | |
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| | | | NOTIFICATION DATE | DELIVERY MODE |
| | | | 06/11/2009 | ELECTRONIC |

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

Notice of the Office communication was sent electronically on above-indicated "Notification Date" to the following e-mail address(es):

efiplaw@us.ibm.com PTOCommunications@hoffmanwarnick.com

| Office Action Summary | | Applicati | on No. | Applicant(s) AMERICA, WILLIAM G. | | | |
|---|--|---|---|---|--------------|--|--|
| | | 10/709,7 | 76 | | | | |
| | | Examine | | Art Unit | | | |
| | | JUNGHW | A M. IM | 2811 | | | |
| The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply | | | | | | | |
| WHIC - Exten after 9 - If NO - Failur Any re | DRTENED STATUTORY PERIOD FOR F HEVER IS LONGER, FROM THE MAILIN sions of time may be available under the provisions of 37 C SIX (6) MONTHS from the mailing date of this communicati period for reply is specified above, the maximum statutory e to reply within the set or extended period for reply will, by apply received by the Office later than three months after the d patent term adjustment. See 37 CFR 1.704(b). | NG DATE OF TH CFR 1.136(a). In no evi ion. period will apply and w statute, cause the app | HIS COMMUNICATIC ent, however, may a reply be t rill expire SIX (6) MONTHS fror Dication to become ABANDON | ON. imely filed in the mailing date of this of ED (35 U.S.C. § 133). | · | | |
| Status | | | | | | | |
| 2a)⊠ 3)□ | Responsive to communication(s) filed on This action is FINAL . 2b) Since this application is in condition for a closed in accordance with the practice ur | This action is r | non-final. for formal matters, pr | | e merits is | | |
| Dispositi | on of Claims | | | | | | |
| 5)□ 6)⊠ 7)□ 8)□ Applicatio 9)□ - | Claim(s) 21-26 is/are pending in the application (s) 21-26 is/are pending in the application (s) is/are with Claim(s) is/are allowed. Claim(s) 21-26 is/are rejected. Claim(s) is/are objected to. Claim(s) are subject to restriction are subject to restriction are subject to restriction are specification is objected to by the Example of the drawing(s) filed on 27 March 2004 is/ Applicant may not request that any objection is Replacement drawing sheet(s) including the organization. | thdrawn from co and/or election r aminer. /are: a)⊠ accep to the drawing(s) b correction is requir | equirement. oted or b) objected oe held in abeyance. Se red if the drawing(s) is of | ee 37 CFR 1.85(a). bjected to. See 37 C | FR 1.121(d). | | |
| 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152. | | | | | | | |
| Priority u | nder 35 U.S.C. § 119 | | | | | | |
| 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. | | | | | | | |
| 2) D Notice 3) D Inform | (s) e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (PTO-94 nation Disclosure Statement(s) (PTO/SB/08) No(s)/Mail Date | 48) | 4) Interview Summar Paper No(s)/Mail [5) Notice of Informal 6) Other: | Date | | | |

DETAILED ACTION

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 21-26 are rejected under 35 U.S.C. 103(a) as being unpatentable over Smith et al (US Pat. 6,255,233), hereinafter Smith in view of Todd (US Pat. 6,733,830).

Regarding claim 21, insofar as understood, Fig. 3 of Smith shows a semiconductor device comprising:

a substrate [50; wafer substrate] including silicon;

a dielectric [150,160, 180, 190, 200] atop the substrate, the dielectric layer including a first dielectric sub-layer [200; SiOF], a second dielectric sub-layer [180; SiN] and a first non-discrete transitional dielectric sub-layer [190; graded silicon oxynitride; col. 3, lines 51-57] residing between the first and second dielectric sub-layer layer, wherein the first dielectric sub-layer has an etch resistance different than the second dielectric sub-layer, and an opening [185] extending no deeper than the sub-layer nearest the substrate; and

wherein a composition of the first non-discrete transitional dielectric sub-laver varies gradually through thickness thereof from a first composition substantially the same as the first dielectric sub-layer where the first non-discrete transitional dielectric sub-layer contacts the first dielectric sub-layer to a second composition substantially the

same as the second dielectric sub-layer where the first non-discrete transitional dielectric sub-layer contacts the second dielectric sub-layer (Abstract).

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Fig. 3 of Smith shows most aspects of the instant invention except the first sub-layer includes at least one component not included in the second sub-layer, the at least one component including "at least one fluoro-substituted analog of one of an organic alkylsiloxane and an organic alkoxysilane." Todd discloses the first dielectric sub-layer includes at least one component not included in the second sub-layer, that is, the first dielectric sub-layer being fluorinated through the at least one component being selected from a group consisting of perfiuoroalkyl group, that is, fluoro-substituted analog of an organic alkylsiloxane (col. 9, lines 14-56). It would have been obvious to one of ordinary skill in the art at the time of the invention was made to incorporate the teachings Todd of into the device of Smith in order to have the first sub-layer including at least one component not included in the second sub-layer, the at least one component being selected from a group including fluoro-substituted analog of an organic alkylsiloxane to reduce the etch rate.

Regarding claim 22, Fig. 3 of Smith shows that an etch resistance of the first dielectric sub-layer [SiOF] is greater than an etch resistance of the second dielectric sub-layer [SiN].

Regarding claim 23, Fig. 3 of Smith shows that the first dielectric sub-layer [SiOF; fluorinated silicon oxide] has a greater content of fluorine than the second dielectric sub-layer [SiN].

Regarding claim 24, Todd discloses the first dielectric sub-layer includes at least one component not included in the second sub-layer, that is, the first dielectric sub-layer being fluorinated through the at least one component being selected from a group consisting of methylsiilane, dimethylsilane, trimethylsilane, trifluorvmethylsilane, 1,2-disitanotetrafluorethylene, 1,3-bis(silanodifluoromethylene)disiloxane, 2,2-disilanohexafluorosilane, bis(trifluoromethyfdisiloxanyl)difluormethane, octamethylcyclotetrasiloxane, and tetramethylcyclotetrasiloxane (col. 7, lines 48-55).

Regarding claim 25, Fig. 3 of Smith shows that the dielectric layer includes a third dielectric sub-layer [150; SiN] residing between the substrate and the first dielectric sub-layer and a second non-discrete transitional dielectric sub-layer [160; graded silicon oxynitride; col. 3, lines 51-57] residing between the third dielectric sub-layer and the first dielectric sub-layer.

Regarding claim 26, Fig. 3 of Smith shows that the second dielectric sub-layer [180; SiN] and the third dielectric sub-layer [150; SiN] have substantially the same etch resistance.

Response to Arguments

Applicant's arguments filed 2/26/2009 have been fully considered but they are not persuasive. The rejection stands, modified only to accommodate the amendments made to the claims by Applicant. New rejections are made in response to Applicant amended claims. In addition, the examiner presents the remarks below in response to Applicant's arguments.

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Applicant argues that "Todd does not teach the use of an alkylsiloxane at all, much less a fluoro-substituted analog of an organic alkylsiloxane." This is not persuasive since Todd discloses that (fluoroalkyl)fluorosiloxanes of are used where of the formula $[(R_f)_{3-x-y}R^1_xF_y)Si]_20$ where R_f is a perfluoromethyl, perfluoroethyl or perfluoropropyl group.

Conclusion

Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

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Any inquiry concerning this communication or earlier communications from the examiner should be directed to JUNGHWA M. IM whose telephone number is (571)272-1655. The examiner can normally be reached on MON.-FRI. 7:30AM-4:00PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Lynne A. Gurley can be reached on (571) 272-1670. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

/Lynne A. Gurley/ Supervisory Patent Examiner, Art Unit 2811

/J. M. I./ Examiner, Art Unit 2811 Application/Control Number: 10/709,776

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